REMARKS

Reconsideration and allowance of the subject application are respectfully requested. Claims 1-11 are pending in the present application, claims 5-11 have been withdrawn. Claims 1 and 4 have been amended.

Specification Objection

The disclosure has been objected to for informalities. In particular the Examiner has suggested changing "7" to "8" on page 7, line 20, and changing "6" to "7" on page 7, line 21. The specification has been amended in accordance with the Examiner's suggestions. Accordingly, Applicants respectfully request that the Examiner reconsider and withdraw the specification objection.

Drawing Objections

The Examiner has objected to Figure 7 with reference to item 233, since allegedly item 233 was not mentioned in the disclosure. The Examiner's attention is directed to the attached replacement drawing of Figure 7 wherein item 233 has been removed making the Examiner's objection is moot. Accordingly, Applicants respectfully request that the Examiner reconsider and withdraw the drawing objection.

Prior Art Rejections

1. Rejection under 35 U.S.C. § 103 (a) based on Kinoshita in view of Kanai

Claims 1-3 stand rejected under 35 U.S.C. § 103(a) as being unpatentable over Kinoshita et al. (JP 2001-137800) in view of Kanai et al. (U.S. Patent No. 5,520,740). This rejection is respectfully traversed.

As set forth on pages 3-4 of the Office Action, the Examiner alleges that Kinoshita teaches a method of treating a surface comprising the steps of supplying a humidified inert gas and irradiating the treating surface of a substrate with ultraviolet rays. The Examiner states that Kinoshita fails to teach removing oxygen on and in the vicinity of the treating surface of the substrate. The Examiner further alleges that Kanai teaches a method of treating the surface of the substrate wherein the surface of the substrate is purged using an inert gas such as Ar. The Examiner further alleges that the purging mechanism of Kanai would inherently remove oxygen on and in the vicinity of the treating surface of the substrate. Applicants submit, however, that the Office Action fails to make a *prima facie* showing that Kinoshita in view of Kanai renders independent claim 1 and dependent claims 2-3 unpatentable.

As described in the present application (Specification, page 2, ll.2 – page 4) Kinoshita et al. (JP 2001-137800) fails to contain methods to remove oxygen on and in the vicinity of the treating surface of the substrate.

Kanai et al. (U.S. Patent No. 5,520,740) is directed to a method for continuously forming a large area functional deposited film by a microwave

plasma (Kanai, abstract). Kanai states that the apparatus used "may include one or more other film forming vacuum vessels. ... each of the vacuum vessels is isolated one from the other by means of a gas gate..." (Kanai, col. 42, ll. 27-31). Kanai further states "it is required that said gas gate means functions to prevent a film-forming raw material gas used in one vacuum vessel from dispersing into the other vacuum vessel" (Kanai, col. 42, ll. 42-44). Kanai illustrates a method of using gas gates, 1016 and 1017, for blocking the gas in one chamber from flowing into another. However, Kanai is completely silent as to "removing oxygen on ... a treating surface" as in claim 1.

Gas gates, 1016 and 1017, in Kanai are constructed to direct gas perpendicular to the substrate (Kanai, Figures 9(a), 9(b), and 10-15). Kanai illustrates directing the gas of the gas gate perpendicular to the substrate and states: "it is understood that the point where pressure becomes maximum is situated near the central part of the gas gate and thus, the gate gas dividedly flows from the central part toward the respective adjacent vessels" (Kanai, col. 43, ll.67- col. 44, ll. 4; Note Kanai mistakenly refers to Figures 19(a) and (b) which should instead be 9(a) and (b) respectively). In the configuration of Kanai any oxygen layer on the surface is pushed into the surface by the perpendicular gas gate flow, not removed. In the present invention the air curtain box 36 (specification, page 13, ll. 6-9; Figure 3) serves a similar purpose as Kanai's gas gates 1016 and 1017, however the air curtain box 36 is not intended for removing the oxygen on the treating

surface. Thus, Kanai fails to teach, show, or suggest the missing features from Kinoshita.

To establish a *prima facie* case obviousness under 35 U.S.C. § 103, the Examiner has the burden of meeting the following three basic criteria: (1) the prior art must teach or suggest <u>all</u> of the claim limitations; (2) there must be a reasonable expectation of success; and (3) there must be some suggestion or motivation, either in the art or knowledge generally available to one of ordinary skill in the art to modify the reference or to combine teachings (M.P.E.P. § 2143)(emphasis added).

Applicants have already explained why the Examiner's alleged combination of Kinoshita and Kanai fails to teach or suggest all the features of independent claim 1. Therefore, since claims 2 and 3 each depend directly from claim 1, claims 2 and 3 are allowable at least for the reasons generally expressed above with respect to claim 1.

Accordingly Applicants respectfully request reconsideration and withdrawal of the outstanding rejection of claims 1-3 under 35 U.S.C. § 103(a).

2. Rejection under 35 U.S.C. § 103 (a) based on Kinoshita+Kanai+Laethem

Claim 4 stands rejected under 35 U.S.C. § 103(a) as being unpatentable over Kinoshita in view of Kanai as applied to claim 1 and further in view of Laethern et al. (U.S. Patent No. 4,188,199). This rejection is respectfully traversed.

As set forth on pages 4 and 5 of the Office Action, the Examiner states that Kinosshita in view of Kanai fails to teach that the "oxygen or air removing gas is introduced in opposite direction of the substrate transfer direction and the humidified inert gas is introduced obliquely in a forward direction of the substrate transfer direction."

The Examiner alleges that Laethem teaches a method where "the treating gases are introduced at an oblique angle and in the moving direction of the substrate as shown in Figure 2 in order to improve uniform exposure of the surface of the substrate to treating gases (col. 1, ll. 38-60)" (Office Action, page 5).

Amended claim 4 states "removing oxygen or air on ... a treating surface ... by blasting an inert gas on said treating surface at an oblique angle toward an upstream side in a substrate transfer direction..." Laethem fails to show such a feature.

Applicants direct the Examiner's attention to the cited section of Laethem, which states in part:

The subject of this patent application is a coating process by which the quality standards attainable by the prior process can be more easily obtained or can be improved upon. According to the present invention, there is provided a process for forming a metal or metal compound coating on a face of a continuously longitudinally moving glass ribbon which includes the steps of contacting such face while it is at elevated temperature, at a zone along the ribbon path, with a fluid medium consisting of or containing one or more substances which undergo chemical reaction or decomposition to form the metal or metal compound on the face, discharging at least part of the fluid medium against the face as a stream or streams which, or at least one of which , has a velocity component in the direction of movement of the ribbon...(Laethem, col. 1, ll. 38-55).

The cited section in Laethem fails to suggest the blasting of any form of gas.

The Examiner further refers to Figure 2, which shows feed channels 17 and 18, which "by way of example, different vaporized substances entrained in currents of carrier gas can be discharged along feed channels 17 and 18 so that the substances react in the vicinity of the top face of the ribbon and forming a coating thereon" (Laethem, col. 7, ll. 12-16). Laethem shows the use of feed channels for use in coating, however Laethem fails to show "removing oxygen or air on ... a treating surface ... by blasting an inert gas on said treating surface at an oblique angle toward an upstream side in a substrate transfer direction." Therefore, Laethem fails to show, suggest, or teach the missing features of the alleged combination of Kinoshita and Kanai (assuming they are combinable which Applicants do not admit).

Further, Applicants have already explained why the alleged combination of Kinoshita and Kanai fails to teach or suggest the features of independent claim 1, which was relied upon by the Examiner as the basis for rejecting claim 4. Additionally, as discussed above Laethem fails to teach or suggest the lacking features in the alleged combination of Kinoshita and Kanai as applied to claim 1. Therefore, claim 4 is allowable at least for the reasons generally described in the foregoing remarks.

Accordingly Applicants respectfully request reconsideration and withdrawal of the outstanding rejection of claim 4 under 35 U.S.C. § 103(a).

CONCLUSION

In view of the above amendments and remarks, Applicants respectfully request reconsideration and withdrawal of the formal objections and rejections to the claims, and the rejections based on prior art. Because all claims are believed to define over prior art of record, Applicants respectfully request an early indication of allowability.

If the Examiner has any questions concerning this application, the Examiner is requested to contact the undersigned at (888) 510-0695 in the Washington, D.C. area.

If necessary, the Commissioner is hereby authorized in this, concurrent, and future replies, to charge payment or credit any overpayments to Deposit Account No. 50-2852 for any additional fees required under 37 C.F.R. §§1.16 or 1.17; particularly, extension of time fees.

Very truly yours,

KEADY, CICCOZZI & OLDS P.L.L.C.

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